

# Integrated Optics refractometry: Sensitivity in relation to spectral shifts

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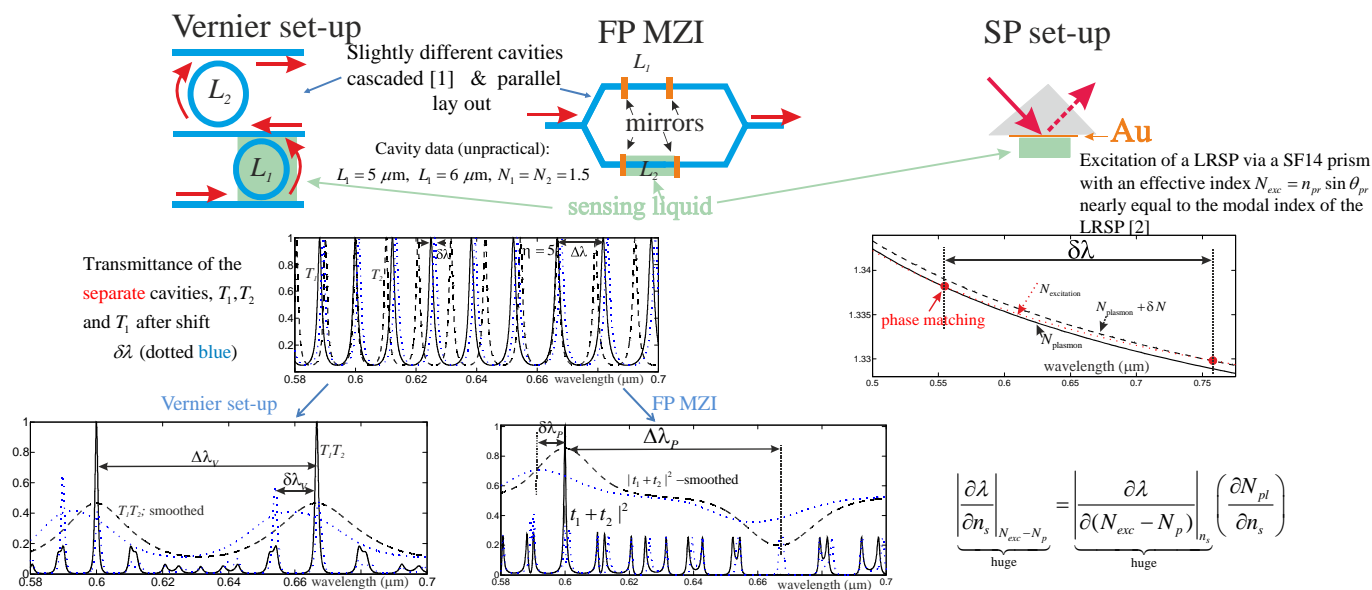
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## Abstract

The poster

- Introduces a new variant to the Vernier-effect based sensor published by reference [1], both showing huge spectral shifts  $\delta\lambda$
- Discusses a few sensors showing huge spectral dependence on the modal index,  $N$ , and on the index of the sensing material,  $n_s$
- And the relevance of such devices for device sensitivity,  $S$

## Sensing devices with principally a huge spectral shift



- Huge spectral shifts in all three devices owing to similarity of sensing part and ‘analyser’ part
- Huge shifts go together with a broad spectral response
- **What does the introduced huge spectral shift mean for the sensitivity?** (nothing!)

## Sensitivity

- Definition of Sensitivity:  $S_n \equiv \left| \frac{\partial \ln T}{\partial n_s} \right|_{\lambda}$  (assuming that noise  $\propto T$ )
- Huge spectral shift in above devices goes together with broad response:

$$\left| \frac{\partial \ln T}{\partial n_s} \right|_{\lambda} = \underbrace{\left| \frac{\partial \ln T}{\partial \lambda} \right|_{n_s}}_{\text{small}} \underbrace{\left| \frac{\partial \lambda}{\partial n_s} \right|_{T}}_{\text{huge}}$$

e.g.  $S_{n, \text{Vernier}} = \left| \frac{\partial \ln T_1 T_2}{\partial n_s} \right|_{\lambda} = \left| \frac{\partial \ln T_1}{\partial n_s} \right|_{\lambda} = S_{n, \text{single cavity}}$  **No effect of huge shift!**

## Conclusions

- Huge spectral shifts in devices as shown above do not increase the sensitivity, but
- relax demands on the resolution of the scanning laser or spectrometer
- The crucial point of large sensitivity in interferometric sensing seems to be the **light-matter interaction**

## Sensitivity, what is relevant?

What is important for a high sensitivity in an interferometric set-up with a (PhC) sensing Waveguide?

reformulation of  $S_n$ :  $S_n = \underbrace{\left| \frac{\partial \ln T}{\partial \beta} \right|_n}_{\text{interferometry}} \underbrace{\left| \frac{\partial \beta}{\partial \lambda} \right|_n}_{\propto 1/v_g} \underbrace{\left| \frac{\partial \lambda}{\partial n_s} \right|_T}_{\propto \Delta_{\text{relative}}}$

- low group velocity (like in PhC and plasmonic waveguides)
- large spectral shift for the response of the waveguide [3]:
 
$$\left( \frac{\partial \lambda}{\partial n_s} \right)_T \propto \int_{\text{unit cell}}^{\text{sensed material}} |E|^2 d\tau / \int_{\text{unit cell}} \epsilon |E|^2 d\tau$$
 corresponding to **strong light-matter interaction**.
- Interferometry to transform modal phase shifts into power changes (MZI, FP) and to increase **light-matter interaction** (FP).

## References

1. T. Claes et al., *Experimental characterization of a Si photonic biosensor consisting of two cascaded ring resonators based on the Vernier effect etc.*, Opt. Expr. 18, 2010, 22747-22761
2. G.G. Nenninger et., *Long-range surface plasmons for high resolution surface plasmon resonance sensors*, Sensors and Actuators B 74, 2001, 145-151
3. J.D. Joannopoulos et al., *Photonic Crystals: Molding the flow of light*, Princeton University, 2008